	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	153	(etch$3 with (SiO2 or "SiO.sub.2" or "silicon oxide" or "silicon dioxide" or (high adj2 k) or "high k" or "high dielectric constant")) same (endpoint or detection) same (radiation or wavelength or intensity)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/10/30 14:18			
2	BRS	L2	101	1 and @pd<="20030929"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/10/30 14:19			
3	BRS	L3	19	DESHMUKH-SHASHANK-C.IN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/10/30 14:19			